

PATENT  
Docket No. 150.0056 0104

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Whonchee Lee et al. ) Group Art Unit: 1765  
  )  
Serial No.: 10/050,639               ) Examiner: Deo  
Confirmation No.: 6476                )  
Filed: 15 January 2002               )  
  )  
For:                                    METHOD AND COMPOSITION FOR SELECTIVELY  
  ETCHING AGAINST COBALT SILICIDE

RESPONSE

Assistant Commissioner for Patents  
Washington D.C. 20231

Dear Sir:

In response to the Office Action dated 9 April 2002, please consider the following  
remarks:

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Remarks

The Office Action dated 9 April 2002 has been received and reviewed. Reconsideration  
and withdrawal of the rejections are respectfully requested.

Allowed Subject Matter

Applicants acknowledge that claims 68-75 are allowed.

Objected to Subject Matter

Applicants acknowledge that claims 47-49 are objected to as being dependent upon a  
rejected base claim, but would be allowable if rewritten in independent form including all of the  
limitations of the base claim and any intervening claims. However, Applicants have not  
rewritten claims 47-49 at this time because it is believed that claim 46, from which claims 47-49  
ultimately depend, is in allowable form.